

United States Patent and Trademark Office



UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
09/652,579	08/31/2000	Vishnu K. Agarwal	98-0616.13	4026
7:	590 12/05/2001			
Charles B Brantley II			EXAMINER	
Micron Technology Inc Mail Stop 525			EVERHART, CARIDAD	
8000 S Federal Way			ART UNIT	PAPER NUMBER
Boise, ID 83716-9632				
			2825	
			DATE MAILED: 12/05/2001	

Please find below and/or attached an Office communication concerning this application or proceeding.

• •	Application No.	Applicant(s)
	09/652,579	AGARWAL, VISHNU K.
Office Action Summary	Examiner	Art Unit
	Caridad M. Everhart	2825
The MAILING DATE of this communication ap	pears on the cover sheet w	ith the correspondence address
3) ☐ Since this application is in condition for allow closed in accordance with the practice under Disposition of Claims 4) ☑ Claim(s) 45-48 is/are pending in the application of the above claim(s) is/are withd 5) ☐ Claim(s) is/are allowed. 6) ☒ Claim(s) 45-48 is/are rejected. 7) ☐ Claim(s) is/are objected to. 8) ☐ Claim(s) are subject to restriction and application Papers 9) ☐ The specification is objected to by the Example 15/278: a) ☐ a	Y IS SET TO EXPIRE 3 M. 136(a). In no event, however, may a ply within the statutory minimum of the will apply and will expire SIX (6) MC te, cause the application to become fing date of this communication, even This action is non-final. wance except for formal mer Ex parte Quayle, 1935 (constant). In a consideration. In a consideration.	MONTH(S) FROM reply be timely filed irty (30) days will be considered timely. NTHS from the mailing date of this communication. ABANDONED (35 U.S.C. § 133). if timely filed, may reduce any natters, prosecution as to the merits is C.D. 11, 453 O.G. 213.
Applicant may not request that any objection to	is: a) approved b)	disapproved by the Examiner.
11) The proposed drawing correction filed on If approved, corrected drawings are required in	n reply to this Office action.	
If approved, corrected drawings are required in	e Examiner.	
12) The oath or declaration is objected to by the	 	•
Priority under 35 U.S.C. §§ 119 and 120 13) Acknowledgment is made of a claim for for	reign priority under 35 U.S	.C. § 119(a)-(d) or (f).
13) Acknowledgment is made or a claim for for	Ioian know) anger an	
a) All b) Some * c) None of:	nents have been received	
1.☐ Certified copies of the priority docur 2.☐ Certified copies of the priority docur	ments have been received	in Application No
- used coning of the	priority documents have t	Jeell tecciaca in time comment
application from the internation	a list of the certified copies	s not received.
A standard of a claim for dor	mestic priority under 35 U.	5.C. 9 119(e) (to a provision at 1
a) ☐ The translation of the foreign languag 15) ☒ Acknowledgment is made of a claim for do	. a acourcional anniicaiiuii i	
Attachment(s)		
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-94 3) Information Disclosure Statement(s) (PTO-1449) Paper N	48) 5) 🔲 Not	erview Summary (PTO-413) Paper No(s) lice of Informal Patent Application (PTO-152) er:

Art Unit: 2825

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

- (e) the invention was described in a patent granted on an application for patent by another filed in the United States before the invention thereof by the applicant for patent, or on an international application by another who has fulfilled the requirements of paragraphs (1), (2), and (4) of section 371(c) of this title before the invention thereof by the applicant for patent.
- 2. Claims 45 and 46 are rejected under 35 U.S.C. 102(e) as being anticipated by Doi(JP8226381).

Doi discloses a method comprising the steps of forming a conductive layer, treating with silane, and forming a second conductive layer.

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are

•

Art Unit: 2825

such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

- The factual inquiries set forth in Graham v. John Deere Co., 383 U.S. 1, 148 USPQ 459 4. (1966), that are applied for establishing a background for determining obviousness under 35 U.S.C. 103(a) are summarized as follows:
 - 1. Determining the scope and contents of the prior art.
 - 2. Ascertaining the differences between the prior art and the claims at issue.
 - 3. Resolving the level of ordinary skill in the pertinent art.
 - 4. Considering objective evidence present in the application indicating obviousness or nonobviousness.
- Claims 45 and 46 are rejected under 35 U.S.C. 103(a) as being unpatentable over Hsieh 5. (US 5,552,339) in view of Yamazaki (JP 55011329, abstract only).

Hsieh discloses the steps of forming a conductor, exposing the conductor to dichlorosilane, and forming a second conductor(col. 2, lines 25-37 and 59-67).

Hsieh discloses dichlorosilane rather than silane.

Yamazaki is relied upon for its teaching of the equivalence of silane and dichlorosilane for the formation of amorphous silicon.

One of ordinary skill in the art would have been motivated to have substituted silane for the dichlorosilane in the process taught by Hsieh in view of the disclosure made by Yamazaki.

Application/Control Number: 09/652,579

Art Unit: 2825

6. Claim 47 is rejected under 35 U.S.C. 102(e) as being anticipated by Li (US 6,136,690).
Li discloses the steps of forming a conductive layer, treating with a plasma comprising H2 and
N2, and depositing a second conductive layer (abstract and col. 6, lines 51-65).

7. Claim 48 is rejected under 35 U.S.C. 103(a) as being unpatentable over Schulz, et al (abstract) in view of IBM Tech. Discl. Bull. Vol. 33, No. 11, p. 352("IBM Discl.").

Schulz et al discloses the steps of forming a conductive layer, treating with an H2 plasma, and treating with silane gas and forming a second conductive layer.

Schulz et al does not disclose H2/N2, although the suggestion that N2 can be used is included in the disclosure in tha N2 is included with a different reducing gas as a possible treatment.

IBM Discl discloses that H2 and N2 in a plasma treatment is used before exposing a surface to silane.

One of ordinary skill in the art would have been motivated to have included N2 in the plasma treatment of the surface taught by Schulz et al in view of the IBM Discl because Schulz et al contained the suggestion of N2 inclusion in a reducing plasma.

Application/Control Number: 09/652,579

Art Unit: 2825

Any inquiry concerning this communication or earlier communications from the examiner should be directed to C. Everhart whose telephone number is (703) 308-3455. The examiner can normally be reached on Mon.-Fri. from 9:00 to 4:30..

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith, can be reached on (703) 308-1323. The fax phone number for the organization where this application or proceeding is assigned is (703) 308-7722 or 308-7724.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956.

C. Everhart

November 7, 2001

CARIDAD EVERHANT PRIMARY EXAMINER